

F-7904

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant : Manfred FRIEDRICH, et al.

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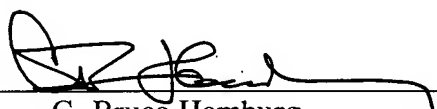
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Sir:

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Respectfully submitted,

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				Filing Date: September 4, 2003		Group:	
<b>U.S. PATENT DOCUMENTS</b>							
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
<b>FOREIGN PATENT DOCUMENTS</b>							
		Document Number	Date	Country	Class	Subclass	Translation Yes      No
TRANSLATION KEY: * English Abstract. <sup>F</sup> Concise statement of relevance provided in foreign search report. <sup>C</sup> Concise statement of relevance provided in specification. <sup>S</sup> Concise statement of relevance provided in IDS. <sup>P</sup> Relevant portion of reference translated. <sup>O</sup> English abstract only - copy of reference in pct search.							
<b>OTHER INFORMATION DISCLOSURE CITATIONS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
		1993; Ion Sources For Accelerators In Materials Research; G.D. Alton; Nuclear Instruments and Methods in Physics Research; pgs. 221-288					
		4/2/93; Sputter Ion Source; High Voltage Engineering Europa B.V.; pgs. 1-18					
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